Supporting Information

Probing Electrochemical Behaviors of {111} and {110} Faceted Hollow Cu$_2$O Microspheres for Lithium Storage

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Fig. S1. SEM image of the commercial Cu$_2$O-NPs.
Fig. S2. HRTEM images of the commercial Cu$_2$O-NPs.

Table S1. BET surface areas of HMs-Cu$_2$O and commercial Cu$_2$O-NPs.

<table>
<thead>
<tr>
<th>Sample</th>
<th>BET surface Area (cm$^3$/g)</th>
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<tr>
<td>HMs-Cu$_2$O</td>
<td>7.05</td>
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<tr>
<td>commercial Cu$_2$O-NPs</td>
<td>6.95</td>
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